

Docket No.: 2336-229

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Young Ho PARK *et al.*

U.S. Patent Application No. 10/735,615

Filed: December 16, 2003

:
:
: Confirmation No. 2726

:
: Group Art Unit: 2829

:
: Examiner: Asok Sarkar

For: METHOD FOR MANUFACTURING GALLIUM NITRIDE-BASED SEMICONDUCTOR LIGHT
EMITTING DEVICE

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

- ☒ No additional fee is required.
☐ Small entity status of this application has been established.
☒ Also attached: **Replacement Figures 1 and 2**

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	7	20	0	x \$ 18 =	\$0
Independent Claims	3	3	0	x \$ 88 =	\$0
If multiple claims newly presented, add \$290.00					-----
Fee for extension of time					-----
TOTAL FEE DUE					\$0

- ☐ A credit card authorization form in the amount of _____ is attached
- ☒ The Commissioner is hereby authorized to charge payment of any *deficiency* in fees associated with this communication or credit any overpayment, to Deposit Account No. 07-1337, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

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AMENDMENT

COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria VA 22313-1450

Sir:

The following amendments and remarks are submitted in response to the Official Action dated *September 10, 2004*.